Notice of Allowability	Application No.	Applicant(s)	
	10/045,781	CHENG ET AL.	
	Examiner	Art Unit	
	Anthony Ojini	3723	
The MAILING DATE of this communication appears on the cover sheet with the correspondence address All claims being allowable, PROSECUTION ON THE MERITS IS (OR REMAINS) CLOSED in this application. If not included herewith (or previously mailed), a Notice of Allowance (PTOL-85) or other appropriate communication will be mailed in due course. THIS NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIGHTS. This application is subject to withdrawal from issue at the initiative of the Office or upon petition by the applicant. See 37 CFR 1.313 and MPEP 1308.			
1. $\boxtimes$ This communication is responsive to <u>amendment filed 02/</u>	<u>13/04</u> .		
2.  The allowed claim(s) is/are <u>1,2,4-12 and 14-17</u> .			
3. $\boxtimes$ The drawings filed on <u>12 January 2002</u> are accepted by the	e Examiner.		
<ul> <li>4. Acknowledgment is made of a claim for foreign priority una)</li> <li>a) All b) Some* c) None of the:</li> <li>1. Certified copies of the priority documents have</li> <li>2. Certified copies of the priority documents have</li> <li>3. Copies of the certified copies of the priority documents have</li> <li>International Bureau (PCT Rule 17.2(a)).</li> <li>* Certified copies not received:</li> </ul>	been received. been received in Application No		tion from the
Applicant has THREE MONTHS FROM THE "MAILING DATE" on noted below. Failure to timely comply will result in ABANDONM THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.		complying with the red	quirements
5. A SUBSTITUTE OATH OR DECLARATION must be submit INFORMAL PATENT APPLICATION (PTO-152) which give			OTICE OF
<ol> <li>CORRECTED DRAWINGS ( as "replacement sheets") mus</li> <li>(a)  including changes required by the Notice of Draftspers</li> <li>1)  hereto or 2)  to Paper No./Mail Date</li> <li>(b)  including changes required by the attached Examiner's Paper No./Mail Date</li> <li>Identifying indicia such as the application number (see 37 CFR 1. each sheet. Replacement sheet(s) should be labeled as such in the</li> </ol>	on's Patent Drawing Review (PTO-S Amendment / Comment or in the O 84(c)) should be written on the drawin	ffice action of	back) of
<ol> <li>DEPOSIT OF and/or INFORMATION about the depose attached Examiner's comment regarding REQUIREMENT I</li> </ol>			Note the
Attachment(s)  1. ☐ Notice of References Cited (PTO-892)  2. ☐ Notice of Draftperson's Patent Drawing Review (PTO-948)  3. ☐ Information Disclosure Statements (PTO-1449 or PTO/SB/06 Paper No./Mail Date  4. ☐ Examiner's Comment Regarding Requirement for Deposit of Biological Material	5. Notice of Informal Pa 6. Interview Summary of Paper No./Mail Date 8), 7. Examiner's Amendman 8. Examiner's Statemen 9. Other	(PTO-413), e nent/Comment	·

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## **REASONS FOR ALLOWANCE**

The following is an examiner's statement of reasons for allowance: the specific limitation of "wherein the sensors (604,606) held in the body are able to detect wafer slippage where a semiconductor wafer and a platen from which the semiconductor wafer can slip both have a substantially identical attribute" in the combination as claimed in claims 1,9, are not anticipated or made obvious by the prior art in the examiner's opinion. For example, Applicant Admitted Prior Art discloses A chemical mechanical polishing (CMP) semiconductor fabrication system comprising: a rotatable polishing pad for polishing a semiconductor wafer (308) using slurry; an oppositely rotatable platen (406) underneath the polishing pad on which the semiconductor wafer is positioned for polishing by the polishing pad; dual sensors (404,405) for detecting semiconductor wafer slippage of the semiconductor wafer from the platen, and a holder (402) to hold the dual sensors at an angle to a vertical plane, the holder having a window exposing the sensors. However, the art of record considered as a whole, alone or in combination fails to provide or suggest "wherein the sensors held in the body are able to detect wafer slippage where a semiconductor wafer and a platen from which the semiconductor wafer can slip both have a substantially identical attribute".

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

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Any inquiry concerning this communication or earlier communications from the examiner should be directed to Anthony Ojini whose telephone number is 703 305 3768. The examiner can normally be reached on 7 to 4 Tuesday-Friday with every other Monday off.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Joseph Hail can be reached on 703 308 2687. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

AO May 3, 2004

Joseph J. Hail, III Supervisory Patent Examiner Technology Center 3700

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